M olecular-orbital theory for the stopping power of atom s in the low velocity regime: the case of helium in alkalimetals.

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Abstract

A free-parameter linear-combination-of-atom ic-orbitals approach is presented for analyzing the stopping power of slow ions moving in a metal. The method is applied to the case of H e moving in alkalimetals. Mean stopping powers for H e present a good agreement with local density approximation calculations. Our results show important variations in the stopping power of channeled atom s with respect to their mean values.

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The interaction of ions with condensed m atter has drawn the attention of m any researchers from the beginning of this century [1]. A great deal of work in this eld has dealt with the energy loss of sw ift ions in solids. In this regard the work of Bethe [2], Ferm i β], W illiams [4], and Lindhard [5] opened the m odern way of calculating the stopping power of sw ift ions in condensed m atter. The case of low -velocity projectiles ism uch m ore com plicated due to the strong interaction of the m oving ion with the solid. In this case, the projectile is dressed by a number of electrons that strongly screen the ion-solid interaction. B randt [6] introduced a Thom as Ferm i statistical m odel in order to de ne an elective ion charge that takes into account how the bound electrons dress the projectile. O ther researchers [7] have developed the Lindhard approach and have calculated the stopping power using a linear-response function. In recent developments [8,9], the stopping power for ions at low and interm ediate velocities has been obtained by introducing the dilerent electron-loss and -capture processes associated with the interaction of the projectile with the target [10].

An in portant development in the calculation of the stopping power for very-low-velocity ions in solids appeared with the application of the local density theory to this eld. Echenique, N iem inen, and R itchie [11] calculated the stopping power for very slow ions moving in a uniform electron gas, using well-known techniques in this eld. This approach has yielded a substantial in provement in the agreement between experimental data and theoretical calculations. The main limitation of this approach, as it has been used in the actual calculations, is the assumption of having an uniform electron gas in the solid. Although some attempts are currently tried to improve over this simplication [12,13], it could be convenient to try, at the same time, other alternatives that might be appropriate in the case of having very ionic or covalent solids.

The aim of the work presented in this paper is to apply to the stopping power eld an approach recently developed for the calculation of electronic properties of solids [14,15]. This is a linear-combination-of-atom ic-orbitals (LCAO) approach, whereby the electronic

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properties of the solids are calculated from the localized wave functions of the atom s of the solid. This approach tries to emphasize the local chem ical properties of the solid and is deeply related to the work done by other groups, trying to calculate the stopping power for ions in solids using the stopping power in the vapour target [16]. The advantage of these approaches is related to the non-uniform ity of the target, since a local-density-approxim ation (LDA) calculation usually assumes a uniform electron gas inside a crystal. Thus the long-term aim of our approach is rst, to calculate the stopping power for ions as a function of the ion position, in particular, near crystal surfaces; and secondly, to take into account the contribution of the di erent atom ic orbitals of the target, m ainly those orbitals which have such a localized size that can not be replaced by an uniform electron gas.

In this paper we have chosen to analyze the case of helium interacting with alkalim etals. This is a case in which the interaction of the projectile and the target is simple. It is, however, a complicated system since it presents a long-range interaction between orbitals located at large separations. In these m etals, the local density approach can be expected to be very good; therefore, we have chosen it as a strong test to the m ethod we have developed, and the results obtained give strong support to it.

In the Secs. II and III, we present our model, the form alism used to solve it, and its application to the case of He in metals. In Sec. IV we discuss our results, and in Sec. V we present our conclusions.

II.M ODEL AND FORM ALISM

A.G eneral form alism

Our model is an extension of a previous approach to the calculation of the electronic properties of the solids using a LCAO method [14,15]. The basic idea is to introduce the atom ic orbitals ; = i; , i referring to the crystal site and to a particular orbital, and the orthonorm albasis

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$$= {}^{X}$$
 (S ${}^{1=2}$) ; ; (1)

with

$$S = h j i;$$
 (2)

obtained using Low din's orthonorm alization procedure [17]. Using this new basis, the electron Ham iltonian of a given system can be written in the following way:

$$\hat{H} = {}^{P}; E \hat{n} + {}^{P};_{\acute{e}}; T (c^{Y}c + c^{+}c) + {}^{P} U^{(0)}\hat{n} \hat{n} \# + \frac{1}{2}{}^{P};_{\acute{e}}; [J^{(0)}\hat{n} \hat{n} + (J^{(0)} J_{x;}^{(0)} + J^{(0)}S^{2})\hat{n} \hat{n}]$$
(3)

with the operators c^{y} and c related to the orthonormalized wave functions . The di erent term s in Eq. (3) are analyzed in Refs. [14] and [15]; here we only comment how to introduce the many-body term s of ham iltonian (3) in a one-body Ham iltonian by means of a Slater-like potential. This implies replacing Eq. (3) by the elective Ham iltonian:

$$\hat{H}_{e} = {}^{X} E \hat{n} + {}^{X} T (c^{+} c + c^{+} c)$$
; ; ; ; ; ; ; (2)

where

$$E^{r} = E + U^{(0)}h\hat{n} i + X + J^{(0)}h\hat{n} i + X + J^{(0)}J_{x}^{0} + J^{(0)}S^{2} + V^{x;c}h\hat{n} i$$
(5)

 $V^{x,c}$ is the exchange and correlation potential [15] associated with the many-body term s of Eq. (3).

W e start from H am iltonian (4) and assume that its solution can be obtained in the static lim it v ! 0, for the case of an atom m oving inside a crystal (see Fig. 1). In our model, the di erent parameters of H am iltonian (4), as well as its static solution, are calculated for a geometrical con guration, at each position of the external atom inside the crystal.

To proceed further, we assume that, due to the atom ic motion, there is a time dependence of ham iltonian (4) through the ion velocity. This im plies introducing a quasiadiabatic Ham iltonian, $\hat{H_e}$ (t), with the di errent parameters, E and T , having an explicit, but slow ly, time dependence.

In order to calculate the stopping power at a given time and atom is position, the static solution of ham iltonian \hat{H}_e is introduced. This implies writing

$$\hat{H}_{eff}$$
 jni= E_n jni: (6)

Then, the stopping power (written as a function of the local timet, de ning the projectile position) is given by the following equation [18]

$$\frac{dE}{dt} = 2Re_{n}^{X} \frac{dt}{dt} dt^{0} \frac{e^{iw_{n0}(t t^{0})}}{w_{n0}} h 0 \frac{d\hat{H}_{e}(t)}{dt} nihn \frac{d\hat{H}_{e}(t^{0})}{dt^{0}} 0i;$$
(7)

[W e are using atom ic units (h = m = e = 1).] Equation (7) is only valid in the quasiadiabatic lim it, with the ion velocity going to zero. Notice that in Eq. (7), the eigenstates jni correspond to the full H am iltonian \hat{H}_e , including the external ion, at the naltimet. This approximation is obviously only appropriate for v ! 0.

Equation (7) can be further modiled by noting that the dependence of \hat{H}_e with t appears through the coordinate $R = R_0 + vt$, of the external atom. Thus we write $\frac{d\hat{H}_e}{dt} = (v - r\hat{H}_e)$, and introduce the Fourier-transform \hat{H}_e (q) of \hat{H}_e (R). This yields

$$\frac{dE}{dt} = 2Re_{n}^{X} \frac{dq}{(2)^{3}} \frac{dq^{0}}{(2)^{3}} \frac{d}{(2)^{3}} \frac{d}{1} \frac{e^{iw_{n0}(t t^{0})}}{w_{n0}} (q v) (q^{0} v)$$

$$e^{iq (R_{0} + vt)} e^{iq^{0} (R_{0} + vt^{0})} h0 j\hat{H}_{eff} (q) jnihn j\hat{H}_{eff} (q^{0}) j0i: (8)$$

This equation can be easily integrated on t° . Moreover, we introduce the one-electron eigenfunctions and eigenvalues, jki, "_k of Ham iltonian \hat{H}_{e} in Eq. (8) to de ne jni and w_{n0} .

These steps yield the following results:

$$\frac{dE}{dt} = 4 \frac{X}{_{khk_{F};k^{0}ik_{F}}} \frac{Z}{(2)^{3}} \frac{dq}{(2)^{3}} \frac{dq^{0}}{(2)^{3}} \frac{(q \ v)(q^{0} \ v)}{w_{kk^{0}}}$$

$$hk^{0} j\hat{H}_{e} (q)e^{iq \ R} jkihk j\hat{H}_{e} (q)e^{iq^{0} \ R} jk^{0}i$$

$$(w_{kk^{0}} + q \ v); \qquad (9)$$

where the spin has been added up and $w_{kk^0} = "_{k^0} "_k$. Note that jki and "_k are the eigenfunctions and eigenvalues of the total H am iltonian, $\hat{H_e}$ (R), with the external ion

included. One should remember, however, that jki and jk^0i are not eigenfunctions of $\hat{H_e}$ (q) :

$$\hat{H}_{e}(q) = dR^{0} e^{iq R^{0}} \hat{H}_{e}(R^{0}):$$
(10)

It is of interest to make contact between Eq. (9) and the linear-response theory. In this case, the total H am iltonian is written as the sum of the unperturbed ham iltonian \hat{H}_0 and a perturbation $\hat{H}_{pert} = \hat{V}$. Then, Eq. (9) can be transformed by taking for jki and jk⁰i, the eigenfunctions of \hat{H}_0 ; moreover, the perturbation \hat{V} , can be written as follows:

$$\hat{\mathbf{V}} = \frac{\mathbf{Z}}{\mathbf{jR} + \mathbf{rj}} (\mathbf{r}); \qquad (11)$$

where Z is the external ion charge and R its position. Then, the power loss is given by the following equation (linear theory):

$$\frac{dE}{dt} = 4 \frac{X}{_{khk_{F},k^{0}ik_{F}}}^{Z} \frac{dq}{(2)^{3}} \frac{Z}{(2)^{3}} \frac{dq^{0}}{(2)^{3}} \frac{4Z}{q^{2}} \frac{4Z}{q^{0}} \frac{4Z}{q^{0}} (q v)$$

$$e^{i(q q^{0}) R}hk^{0}j^{+}(q)jkihkj(q^{0})jk^{0}i(w_{kk^{0}}+q v)$$
(12)

or, equivalently,

$$\frac{dE}{dt} = 2 \frac{Z}{(2)^{3}} \frac{dq}{(2)^{3}} \frac{4}{q^{2}} \frac{Z}{q^{2}} \frac{4}{q^{2}} \frac{Z}{q^{2}} (q v)$$

$$e^{i(q q^{0}) R} \operatorname{Im} (q;q^{0}; q v); \qquad (13)$$

where $Im (q;q^0;w)$ is the metal polarizability.

For an hom ogeneous system , only $q = q^0$ contributes, and Eq. (13) yields

$$\frac{dE}{dt} = 2 \left[\frac{dq}{(2)^3} - \frac{4}{q^2} \frac{$$

in agreem ent with other Refs. [5,18]. Equation (9) is the basic equation giving the stopping power of the moving ion, in the low velocity limit, within our LCAO approach. In Eq. (9) the critical quantity to calculate, using the static interaction between the external charge and the solid, is hk $j\hat{H}_{e}$ (q) $jk^{0}i$. In this paper we shall concentrate on the He case; this provides a simple case in which to test the method discussed here. In this section, we will present a sum mary of the main results discussed in Ref. [14]. We shall also extend this discussion in order to calculate the matrix elements hk $j\hat{H}_{e}$ (q) $jk^{0}i$, needed for the calculation of the stopping power. Following Ref. [14], we start by considering the one-electron interactions between the He 1s level and a metal band that is represented in Fig. 2 by a half-occupied s level. As discussed in Ref. [14], there are two di erent one-electron interactions. First, due to the overlap S between the He 1s wave function and the metal orbital (S = h_M j_{He}i), there is an increase in the kinetic energy of the electrons of the system. This is measured by the following shift of the one-electron term s:

$$E_{M}^{(1)} = \frac{1}{4} S^{2} (E_{M}^{0} - E_{He}^{0}) - ST;$$
(15)

$$E_{He}^{(1)} = \frac{1}{4} S^{2} (E_{M}^{0} - E_{He}^{0}) - ST; \qquad (16)$$

where T, the hopping between the two orbitals, $_{M}$ and $_{He}$, is found to be $\frac{1}{2}S (E_{M}^{0} E_{He}^{0})$. E_{M}^{0} and E_{He}^{0} are the m etal and H e energy levels. Second, due to the hopping T between the two orbitals we nd a hybridization contribution to the total energy given by the following shift in E_{M}^{0} and E_{He}^{0} :

$$E_{M}^{(2)} = \frac{T^{2}}{(E_{M} - E_{He})};$$
(17)

$$E_{\rm H\,e}^{(2)} = \frac{T^2}{(E_{\rm M} - E_{\rm H\,e})};$$
(18)

Combining Eqs. (15)-(18), we nd the following contributions:

$$E_{\rm M} = S^2 (E_{\rm M} E_{\rm He}); \qquad (19)$$

$$E_{\rm H\,e} = 0$$
: (20)

These shifts in the one-electron levels yield the following contribution to the repulsive energy:

$$V_{\text{repulsive}}^{\text{one electron}} = n_{\text{M}} S^2 (E_{\text{M}} E_{\text{He}}); \qquad (21)$$

where n_M is the number of electrons in the metal orbital.

M any-body contributions have also been discussed in Ref. [14]. These terms can be written in a way sim ilar to Eq. (21); in Ref. [14] it was found that the total repulsive energy between the metal atom and He is given by

$$V_{\text{repulsive}}^{\text{one electron}} = n_{M} S^{2} (E_{M} E_{He}) + n_{M} (J_{x}^{0} + S^{2} J_{0}) + V_{\text{electrostatic}};$$
(22)

where J_x^0 is the exchange integral between the metal and the He orbitals, J_0 the C oulomb interaction between the same orbitals, and $V_{electrostaric}$ the electrostatic interaction between the total charges of the two atoms. For a He-orbital going like $(-3)^{1-2}e^{-r}$ we not that

$$J_x^0 + V_{\text{electrostatic}} = \frac{3}{8} S^2 :$$
 (23)

This shows that the repulsive potential can be written as follows:

$$V_{\text{repulsive}} = n_{M} S^{2} (E_{M} E_{He} \frac{3}{8} + J_{0}):$$
 (24)

In our actual problem we are interested in calculating $hk^0 j\hat{H}_e(R) jki$, the matrix element of the total H am iltonian between the one-electron states jki. We will show how Eq. (24) can be related to $hk^0 j\hat{H}_e(R) jki$. To this end, we start by discussing the solution of the total H am iltonian (crystal plus the external atom) within a one-electron approximation. The solution of this H am iltonian \hat{H} is given by

$$= \int_{k}^{X} c_{k k} + c_{He He}; \qquad (25)$$

where $_{k}$ are the eigenfunctions of the crystal H am iltonian, $\hat{H_{0}}$, and $_{He}$ the 1s orbital of He. In writing Eq. (25), we assume that the total H am iltonian (in our one-electron approximation) is given by $\hat{H} = \hat{H_{0}} + \hat{V}_{He}$, where \hat{V}_{He} denes the one-electron potential created by the atom. The eigenvalues and the eigenfunctions of \hat{H} are given by the secular equation

det jh_i j E +
$$\hat{H}$$
 j j $\hat{j} = 0$: (26)

Now, we follow Ref. [14] and introduce the orthonormalized wave functions [as done in Eq. (1) for the basis]

$$_{i} = \sum_{i^{0}}^{X} (S^{1=2})_{ii^{0}} _{i^{0}}; \qquad (27)$$

with

$$S_{kHe} = h_k j_{He} i; \qquad (28)$$

and

$$S_{kk^0} = h_k j_{k^0} = 0$$
: (29)

Using Eq. (27) we de ne the following e ective ham iltonian

$$\hat{H}_{e} = S^{1=2} \hat{H} S^{1=2}$$
: (30)

In Ref. [14], the diagonal term s of the elective H am iltonian were calculated up to second order in the overlap, a small parameter used for calculating S¹⁼² in a series expansion, while the o-diagonal term s were only obtained up to rst order. In our actual problem we need to calculate (\hat{H}_{e})_{kk⁰} up to second order in the overlap, the smallest surviving term of the expansion.

Proceeding in this way, we obtain the following results:

$$(\hat{H}_{e})_{kHe} = T_{kHe} = \frac{1}{2} S_{kHe} (E_{k}^{0} - E_{He}^{0}); \qquad (31)$$

$$(\hat{H}_{e})_{kk^{0}} = T_{kk^{0}} = (V_{He})_{kk^{0}} - \frac{1}{2} (T_{kHe}S_{Hek^{0}} + T_{k^{0}He}S_{Hek}) + \frac{1}{4} (\frac{E_{k}^{0} + E_{k^{0}}^{0}}{2} - E_{He})S_{Hek^{0}}S_{Hek};$$
(32)

where E_k^0 and E_{He}^0 are the k-state and the atom ic levels, respectively.

Equation (31) was already discussed in Ref. [14], and found to be valid for a very localized wavefunction like the He 1s level. Equation (32) is the new equation we are looking for; here

 $(V_{H e})_{kk^0}$ is associated with the direct perturbation introduced by the He atom on the metal. This perturbation is basically due to the atom ic Hartree potential, and to the exchange perturbation created by the He 1s level.

Equations (31) and (32) can be further approximated by taking E_k^0 , the one-electron k state levels, equal to E_M^0 a mean level of the metal band (notice that the He level E_{He}^0 is very deep and that replacing E_k^0 by E_M^0 is a good approximation). Then Eqs. (31) and (32) read

$$T_{kHe} = \frac{1}{2} S_{kHe} (E_M E_{He}); \qquad (33)$$

$$T_{kk^{0}} = (V_{He})_{kk^{0}} - \frac{1}{2} (T_{kHe}S_{Hek^{0}} + T_{k^{0}He}S_{Hek}) + \frac{1}{4} (E_{M} - E_{He})S_{Hek^{0}}S_{Hek}$$

= $(V_{He})_{kk^{0}} + \frac{3}{4} (E_{M} - E_{He})S_{Hek^{0}}S_{Hek}$: (34)

The term s appearing in Eq. (34), that depend on T_{kHe} and S_{kHe} , are equivalent to the ones going like (ST), in Eq. (15), if T is replaced here by $\frac{1}{2}S (E_M = E_{He})$; this shows how the one-electron correction to the metal level $\frac{3}{4}S^2 (E_M = E_{He})$ coincides with the one-electron contribution to the o-diagonal term in T_{kk^0} if S^2 is replaced by $S_{kHe}S_{Hek^0}$.

Returning to Eq. (33), we should comment that T_{kHe} is a rst order term in the overlap S_{Hek} while T_{kk^0} is second order $[(V_{He})_{kk^0}$ included]. The rst order term T_{kHe} introduces an elective second order contribution to T_{kk^0} given by

$$\frac{\mathrm{T}_{\mathrm{kH}\,\mathrm{e}}\mathrm{T}_{\mathrm{H}\,\mathrm{ek}^{0}}}{\mathrm{E}_{\mathrm{M}}^{0}-\mathrm{E}_{\mathrm{H}\,\mathrm{e}}^{0}};$$
(35)

Combining Eqs. (33) and (34) with Eq. (35) we get the following e ective interaction:

$$T_{kk^{0}} = (V_{He})_{kk^{0}} + (E_{M}^{0} - E_{He}^{0})S_{kHe}S_{Hek^{0}}:$$
(36)

This is the one-electron contribution to the elective hopping between the crystal wave functions jki and $jk^{0}i$, as induced by the external atom. When the crystal wavefunctions jki are developed in a local basis

$$jk > = \sum_{i}^{X} c_{i}(k) i; \qquad (37)$$

 $_{\rm i}$ being the orthonormalized wave functions associated with the metal atom , Eq. (36) reads as follows:

$$T_{ii^{0}} = (V_{He})_{ii^{0}} + (E_{M}^{0} - E_{He}^{0})S_{iHe}S_{Hei^{0}};$$
(38)

Equation (38) is the fundam ental equation m aking contact between the repulsive potential given by Eq. (19) and T_{ii^0} . M any-body contributions are partially taken into account in Eq. (38) by means of the term $(V_{H e})_{ii^0}$ which includes the bare H artree and bare exchange contributions, equivalent to $V_{electrostatic}$ and J_x^0 in Eq. (22). The extra term S^2J_0 , appearing in Eq. (22) is due to the e ect of the overlap between the jki and He orbitals in the total exchange interaction.

This discussion and the results of Eq. (38) suggest to introduce the following e ective interaction between the i and i^0 orbitals

$$(T_{e})_{\underline{i}\underline{i}^{0}} = S_{\underline{i}\underline{H}\,e}S_{\underline{H}\,e\underline{i}^{0}} (E_{M}^{0} - E_{\underline{H}\,e}^{0} - \frac{3}{8} + hJ^{0}\underline{i}):$$
(39)

This equation should be compared with Eq. (24) that yields the total repulsive potential between H e and the m etal atom s.

In this equation, hJ^0i is associated with the e ect of the overlap between the He 1s orbital and the atom ic wave functions of the m etal in the exchange interaction created by the He-orbital. In Eq. (24), J^0 is the C oulom b interaction between the atom ic wavefunction and the He 1s orbital; in Eq. (39) we have introduced hJ^0i , the mean value of this C oulom b interaction in the crystal unit cell (the change of J^0 along this unit cell is small, less than 10%).

Equation (39) is the main equation giving the elective matrix elements creating the excitation between the i and i^0 orbitals, or the Bloch wave functions jki and jk⁰i in the crystal, in this basis:

$$(T_{e})_{kk^{0}} = S_{kHe}S_{Hek^{0}} (E_{M}^{0} - E_{He}^{0} - \frac{3}{8} + hJ^{0}i):$$
(40)

Once we have obtained the static interaction of He with the metal, and the elective matrix elements, we will discuss how to combine this result with the general Eq. (9) to calculate the stopping power for He. First of all, let us mention that we shall use Eq. (9) by assuming that jki and $jk^{0}i$ are well described, for the He case, by the unperturbed crystal wave functions. This is a good approximation in our current case due to the small overlap between the He 1s and the localized metal wave functions.

Then, the starting point is the equation

$$[\hat{\mathbf{f}}_{e} (\mathbf{R})]_{kk^{0}} = V_{0} \mathbf{S}_{kH e} \mathbf{S}_{H ek^{0}};$$
(41)

where

$$V_0 = (E_M \quad E_{He} \quad \frac{3}{8} + hJ^0i):$$
 (42)

The overlap between the 1s He state and the jki wave functions is written in the following way

$$hk j_{He}i = dr_{k}(r)_{He}(r)'_{k}(R_{He}) dr_{He}(r); \qquad (43)$$

where we replace $_{k}$ (r) by $_{k}$ (R $_{He}$), assuming the He 1s level to be very localized. This allow sus to write:

$$k j \hat{H}_{e} (R) j k^{0} i = V_{0 k} (R_{He}) _{k^{0}} (R_{He}) [dr_{He} (r)]^{2}$$

$$= V_{0 k} (R_{He}) _{k^{0}} (R_{He}) :$$
(44)

This yields [see Eqs. (9), (10)]

$$H_{e}(q) = V_{0}^{0} dR e^{iq R}_{k}(R)_{k^{0}}(R)$$

$$= V_{0}^{0} I_{kk^{0}}(q)$$
(45)

and

$$\frac{dE}{dt} = 4 \frac{X}{k_{kk_{F}}, k^{0}i_{k_{F}}} (V_{0}^{0})^{2} \frac{Z}{(2)^{3}} \frac{dq}{(2)^{3}} \frac{dq^{0}}{(2)^{3}} \frac{(q \ v)(q \ v)}{w_{kk^{0}}}$$

$$I_{kk^{0}}(q) I_{k^{0}k}(q^{0}) e^{i(q \ q^{0}) R} (w_{kk^{0}} + q \ v): \qquad (46)$$

This is the general equation giving the power loss at a given point R. Notice that due to the crystal simmetry $k^0 = k$ q and $q^0 = q$ G, G being a crystal reciprocal vector.

If we are only interested in the m can power loss and neglect the R dependence, we should concentrate on the $q = q^0$ contribution. Then Eq. (46) yields

$$\frac{dE}{dt} = 4 \left(V_0^0 \right)^2 \frac{1}{1} \frac{dk}{(2)^3} \frac{1}{1} \frac{dq}{(2)^3} (q \ v) (k_F \ k) (k^0 \ k_F) I_{kk^0}(q) I_{k^{0}k}(q) (w_{kk^0} + q \ v);$$
(47)

with $k^0 = k$ q and is the step function.

Equation (47) depends on the velocity direction of the projectile. As we shall only consider the case of H e m oving in alkalim etals, crystals that have a very sm all anisotropy, we shall calculate the stopping power by taking an average on all the v directions, which will enable us to compare our results with other works [11]. Then:

$$\frac{1}{v}\frac{dE}{dx} = \frac{\prod_{1}^{R_{1}} d\cos v dE = dt}{2 v^{2}};$$
(48)

which rede nesdE =dx.

Equation (47) is our fundamental equation for calculating the stopping power for He, in the low-velocity limit. This equation can be written in a local basis by developing the k states in the atom ic orbitals of the crystal. In general, we shall assume that the metal wavefunctions are given by an electric one-electron Ham iltonian \hat{H}_0 , such that

$$\hat{H}_{0}$$
 jki= E (k) jki: (49)

Then, the solution of this ham iltonian yields

$$jki = \int_{i}^{X} c(k)e^{ikR_{i}} (rR_{i});$$
 (50)

where $_{i}$ (r R $_{i}$) are the orthonormalized wave functions associated with the i site (measures the number of orbitals per site). On the other hand $_{i}$ (r R $_{i}$) should be expressed as a function of the localized atom ic orbitals $_{i}$ (r R $_{i}$) using Eq. (1). By substituting Eqs. (50) and (1) into Eq. (47), we not the following result

where

$$I^{R_{1}}(q) = dr e^{iq r} (r) (r R_{1});$$
 (52)

$$(S(k)^{1=2}) = \sum_{R}^{X} e^{ik R} (S^{1=2}(R));$$
 (53)

$$S(k) = \int_{R}^{X} e^{ik R} dr$$
 (r) (r R): (54)

Finally, we relate c (k) c (k) to the metal G reen functions G (k; w) by the equations

$$(k_F \ k)c(k)c(k) = \frac{1}{2} \int_{1}^{Z_{F}} dw \text{Im } G(k;w)$$
 (55)

$$(k^{0} k_{F})c(k)c(k) = \frac{1}{E_{F}}^{Z_{1}} dw \text{Im } G(k;w):$$
 (56)

Thisyields

$$\frac{1}{v}\frac{dE}{dx} = 2 (V_0^0)^2 \int_{1}^{Z_{11}} d\cos v \int_{1}^{Z_{11}} \frac{dk}{(2)^3} \int_{1}^{Z_{11}} \frac{dq}{(2)^3} \frac{(q v)}{v^2}$$

$$X X \qquad \text{Im } [G (k)] \text{Im } [G (k)]$$

$$\int_{X}^{R_1,R_2} ;;;$$

$$(S (k)^{1=2}) \circ I_{0}^{R_{10}} (q) (S (k)^{1=2}) \circ$$

$$\int_{Y}^{0;0} (S (k^0)^{1=2}) \circ I_{0}^{R_{00}} (q) (S (k^0)^{1=2}) \circ$$

$$e^{i(k q)(R_1 R_2)} (w_{kk^0} + q v); \qquad (57)$$

where

$$G (k) = \int_{1}^{Z} \frac{dw}{dt} G (k; w)$$
(58)

and

$$G (k^{0}) = \int_{1}^{Z_{E_{F}}} \frac{dw^{0}}{G} (k^{0}; w^{0}):$$
 (59)

Equation (57) allows us to calculate the stopping power for H e in m etals, as a function of the G reen-function components G (k) of the m etal (calculated in the orthonormalized basis), using a one-electron ham iltonian \hat{H}_0 (k) and the overlap m atrix S¹⁼² (k) associated with the atom ic wave functions and . Moreover, $\frac{1}{v} \frac{dE}{dx}$ also depends on I^R (q), the Fourier-transform of the overlap between the atom ic orbitals (r) and (r R) as given by Eq. (52).

On the other hand, in order to analyze the stopping power as a function of R we take in Eq. (46) $q^0 = q$ G, and only the G vectors perpendicular to the v direction. This yields for the G component of $\frac{1}{v} \frac{dE}{dx}$,

$$S_{G} = \frac{1}{v} \frac{dE}{dx} \Big|_{G}^{2} = 4 \left(V_{0}^{0} \right)^{2} \frac{Z_{1}}{1} \frac{dk}{(2)^{3}} \frac{Z_{1}}{1} \frac{dq}{(2)^{3}} \frac{dq}{v^{2}} \left(\frac{q}{v^{2}} \right) \left(\frac{k}{F} - \frac{k}{k} \right) \left(\frac{k}{v^{0}} - \frac{k}{k_{F}} \right)$$

$$I_{kk^{0}} \left(q \right) I_{k^{0}k} \left(q - \frac{G}{v} \right) e^{\frac{iG}{v^{0}} - \frac{R}{v^{0}}} \left(\frac{w_{kk^{0}} + q}{v^{0}} - \frac{v}{v} \right); \quad (60)$$

and remember that $k^0 = k q$.

This equation can be written in a way similar to Eq. (57), as a function of S (k), G (k) and, I^{R} . For the sake of brevity, we shall only mention here that in general the stopping power S = $\frac{1}{v} \frac{dE}{dx}$ can be written as follows:

$$S_{R} = S_{0} + \sum_{G}^{X} S_{G} e^{iG R};$$
 (61)

as a function of R, where S_0 is the mean stopping power given by Eq. (57), and S_G the G component of Eq. (60). Once we have chosen the G vectors perpendicular to v, we have calculated S_G by taking an average on the angle between v and q as in Eq. (48).

We have applied the previous form alism to the calculation of the stopping power for He in alkali metals. For simplicity, the band is assumed to be well described by means of a single sorbital. Then, Eq. (51) can be further simplied into the following equation:

$$\frac{1}{v}\frac{dE}{dx} = 2 \left(V_{0}^{0} \right)^{2} \int_{1}^{Z} \frac{1}{d\cos v} \frac{dx}{v} \int_{1}^{Z} \frac{dk}{(2)^{3}} \int_{1}^{Z} \frac{dq}{(2)^{3}} \frac{dq}{v^{2}} \frac{(q - v)}{v^{2}} \left(k_{F} - k \right) \left(k^{0} - k_{F} \right)$$

$$X \left(S (k)^{1=2} \right) I^{R_{1}} \left(q \right) \left(S (k)^{1=2} \right) \left(S (k^{0})^{1=2} \right) I^{R_{2}} \left(q \right) \left(S (k^{0})^{1=2} \right)$$

$$E^{R_{1}R_{2}} \left(e^{i(k - q)(R_{1} - R_{2})} \left(w_{kk^{0}} + q - v \right) \right) \right) \left((62)$$

or

where

$$I^{R_{1}}(q) = dr e^{iq r} (r) (r R_{1})$$
(64)

and

$$S(k) = \int_{R}^{X} e^{ik R} dr (r) (r R):$$
 (65)

Equation (64) can be written in a more symmetric way as follows. Take

$$I^{R_{1}}(q) = e^{iq R_{1}=2} dr e^{iq (r R_{1}=2)} (r) (r R_{1})$$
$$= e^{iq R_{1}=2} I^{R_{1}}(q);$$
(66)

then

$$\sum_{\substack{R_{1} \\ R_{1}}}^{X} e^{i(k q) R_{1}} I^{R_{1}}(q) = \sum_{\substack{R_{1} \\ R_{1}}}^{X} e^{i(k q=2) R_{1}} I^{R_{1}}(q)$$
(67)

and

$$\sum_{\substack{R_{2} \\ R_{2}}} e^{i(k q) R_{2}} I^{R_{2}}(q) = \sum_{\substack{R_{2} \\ R_{2}}}^{X} e^{i(k q=2) R_{2}} I^{R_{2}}(q):$$
(68)

Equations (62) and (63) yield the stopping power for He as a function of S (k) and I R (q). S (k) has been calculated using the atom ic wave functions given in Ref. [19]. The calculation of I R (q) is more complicated since the Fouriertransform of the atom ic wavefuncions centered on di erent sites are needed. This is the well-known problem of multicenter integrals. Several solutions have been tried in the literature [20] such as expanding the Slater-type basis in a Gaussian one [21,22]. We have used, however, an adaptative algorithm of integration by M onte C arlo techniques [23] to perform I R .

An approximate solution, which yields good results for S₀, is obtained by replacing

where

$$S(R) = dr(r)(rR)$$
 (70)

and

$$I(q) = dr e^{iq r} (r) (r):$$
 (71)

Equation (69) is exact in the lim it $R_i = 0$ or q ! 0. In general, we expect Eq. (69) to give a good approximation to $I^{R_i}(q)$ if $q = R_i = 2$ is small.

Introducing Eq. (69) into Eq. (63) yields:

$$\frac{1}{v}\frac{dE}{dx} = 2 \left(V_{0}^{0}\right)^{2} \int_{1}^{z} d\cos v \int_{1}^{z} \frac{dk}{(2)^{3}} \int_{1}^{z} \frac{dq}{(2)^{3}} \frac{dq}{v^{2}} \left(k_{F} - k\right) \left(k^{0} - k_{F}\right)$$

$$\frac{I(q)}{S(k)} \frac{I(q)}{S(k^{0})} \int_{R}^{X} S(R) e^{i(k-q-2)R} \int_{2}^{z} \left(w_{kk^{0}} + q - v\right): \qquad (72)$$

Equation (72) is the basis of our approximation to Eqs. (62) and (63). We should also mention that E_k (the electron energy band of the alkalimetal) has been assumed to follow a free electron dispersion law.

Before discussing the numerical results given by Eq. (72), it is worth considering the results obtained by neglecting all the overlaps between the alkali atom wavefunctions. Then we write

$$S(R) = \begin{cases} 8 \\ \stackrel{\gtrless}{\geq} 1; \quad R = 0 \\ \stackrel{?}{\geq} 0; \quad R \neq 0 \end{cases}$$
(73)

and

$$S(k) = 1$$
 (74)

and replace Eq. (72) by the following equation:

$$\frac{1}{v}\frac{dE}{dx} = 2 \left(V_{o}^{0}\right)^{2} \int_{1}^{z} d\cos v \int_{1}^{z} \frac{dk}{(2)^{3}} \int_{1}^{z} \frac{dq}{(2)^{3}} \frac{dq}{v^{2}} \left(k_{F} - k\right) \left(k^{0} - k_{F}\right) dr \int_{1}^{z} dr \int_{1}^{z} \left(k_{K^{0}} + q - v\right) dr = 0$$
(75)

It is also convenient to discuss at this point the stopping power given by the following simple model: a uniform electron gas interacting with a slowly moving He atom by means of the following contact potential

$$\hat{H}_{pert} = V_0^0 \quad (r \quad vt):$$
(76)

Here V_0^0 is assumed to be the same local potential introduced in Eq. (44). It is an easy task to develop this model following the same steps as discussed above for the LCAO approach and nd the following expression for the stopping power

$$\frac{1}{v}\frac{dE}{dx} = 4 \left(V_0^0\right)^2 \int_{1}^{Z_{1}} \frac{dk}{(2)^3} \int_{1}^{Z_{1}} \frac{dq}{(2)^3} \frac{(q \ v)}{v^2} \left(k_F \ k\right) \left(k^0 \ k_F\right) \left(w_{kk^0} + q \ v\right): (77)$$

The integral in \cos_v equals 2 because in the latter expression $\frac{1}{v} \frac{dE}{dx}$ depends only on jv j.

Comparing Eqs. (75) and (77), we see that their only difference is associated with the term $jI(q) f = j^{R} dr^{2}(r)e^{iq r} f$, which gives the form factor of the metal orbital. We should also comment, regarding Eq. (72) that in the alkalimetals $S(k) = S(k_{F})$ since, in the low velocity limit we are considering k and k^{0} are located near the Ferm isphere, S(k)

being alm ost constant on this surface that presents a very sm all an isotropy. Then, Eq. (72) can be obtained from Eq. (75) by replacing the form factor I(q) by

$$D (q;k) = \frac{I(q)S(k q=2)}{S(k)};$$
(78)

where

$$S(k q=2) = \sum_{R}^{X} S(R) e^{i(k q=2) R}$$
: (79)

Thus the three di erent cases we are considering yield the same equation for the stopping power, but for a speci c factor taking the values 1, I (q) and D (q;k), for the free electron gas (FEG), the LCAO m odel with S (R) = 0 for R \leftarrow 0 (LCAO -I), and the LCAO m odel with S (R) \leftarrow 0 (LCAO -I), respectively. W hat is of interest to realize about this discussion is that the free-electron-gasm odel overestim ates the stopping power, while the sim plest LCAO m odel underestimates it. In Table I, we give the three values of the mean stopping power S₀, for H e in Na as calculated from these equations. As shown in this Table I the free electron del $\frac{1}{v} \frac{dE}{dx}$ is about eight times too small.

O ne word of caution must be put here. The FEG model discussed here can not be compared directly with the LDA used to calculate the stopping power of He in metals. The point to notice is that in the model de ned by Eq. (76), V_0^0 is the contact potential for the interaction of He with the s orbitals of the alkali-metal atom s. The model of Eq. (76) is only introduced here in order to explain how the form factor of Eqs. (78) or (75) is the main term controlling the He stopping power.

As regards the factor D (q;k) used to calculate $\frac{1}{v} \frac{dE}{dx}$ in the LCAO-II approximation, notice the strong dependence that D (q;k) has on the num ber of neighbors used to calculate $S(k) = {P \choose R} S(R) e^{ik R}$ and S(k = q=2) in Eq. (78). We have found that in order to get a reasonable accuracy (around 5%) it is necessary to add up to the ffh or sixth neighbor, depending on the alkalim etal.

As mentioned above, Eq. (63) has been accurately calculated for N a using M onte C arb techniques. We have found that this M onte C arb calculation yields

$$\frac{1}{v}\frac{dE}{dx} = 0.085 au: (Na);$$
 (80)

a value a little larger than the one found using our LCAO -II approximation. By assuming the same correction factor for all the alkalimetals, we nd the results given in Table II, column (a). This Table also shows the theoretical gures obtained by Echenique, Nieminen, and Ritchie [11].

We see from Table II, column (a), that the results for K and Rb are in excellent agreement with Ref. [11], although the stopping powers we nd for Li and Na are a little larger. This di erence can be partially attributed to the simple model we are using, since a single s orbital per alkalim etal atom has been assumed to form the metal conduction band. This approximation can be expected to be a reasonable one for very electropositive atoms like K and Rb, but not so appropriate at least for Li. Thus, in the calculations of Papaconstantopoulos [24] for Li, only 52% of the occupied density of states has a s like character. If we introduce in the results of Table II, a factor

$$n_{s}^{2}=n_{s}^{2}$$
 (Rb) (81)

which norm alizes the stopping power of each alkalim etal to the total number of s electrons with respect to Rb, we nd the results of Table II, column (b), in much better agreement with the LDA calculations.

The conclusion we can draw from these results is that the method developed in this paper is quite appropriate to calculate the stopping power for Hemoving slowly in alkali metals. We can also expect that the method will be useful to calculate stopping powers for atoms in transition metals.

In a further step we have calculated, using M onte C arb techniques, the stopping power dependence on the ion position (for H em oving in a channeled direction). We have considered that H em oves in a N a crystal along the [100] direction. We have calculated the diment G reciprocal vectors contributing to the stopping power [Eq. (60)]; this implies taking the G vectors perpendicular to the [100] direction. In a box lattice, the rst reciprocal vectors to

be considered are the followings: G $\frac{2}{a}$ (0;1;1), $\frac{2}{a}$ (0;0;2) etc. U sing Eqs. (60) and (61) we have obtained the stopping power Fourier components S_G shown in Table III.

Figure 3 shows S_R , with R changing in a [100] plane. The main conclusion we can draw from these calculations is the strong dependence that the stopping power shows as a function of the in pact parameter: the stopping power can vary as much as 100% for dierent in pact distances. We should comment that these changes are not associated with the electronic metal charge [13]; this charge, as obtained in our LCAO approach with an slevel per atom, appears to be almost constant in the crystal lattice except very close to the atom is sites. For a He-atom channeled along the Na [100] direction, one expects some kind of oscillatory motion of the atom, with the impact parameter changing along the He trajectory. Then, the mean-stopping power for the channeled case would appear as an average of the dierent values shown in Fig. 3 around the minimum value of the stopping power. Each case should be analyzed speci cally, but assuming the incoming atom to explore only half of the total available space, one would get around 50-60% of S₀, namely 0.04 a.u., 80% of the value calculated in LDA.

V.CONCLUSIONS

The aim of this work has been to develop a rst-principles, free-parameter, approach based on a LCAO method to calculate the stopping power for atom smoving in condensed matter. In the past few years the interest in, generally speaking, tight-binding methods [25] for analyzing the electronic properties of solids has increased a lot. This emphasis is partially due to the interest in using a local point of view, closely related to the chemistry of the local environment. The work presented in this paper follows this general trend and tries to apply the ideas recently developed in Refs. [14,15] for analyzing the electronic properties of solids following a LCAO method, to the stopping power area. In the long term, this approach can be expected to be also useful for analyzing other dynamical processes like the charge transfer between moving ions and the solid, sticking mechanism s, etc. In Sec. II, we have presented our general approach and have related the stopping power for atom s, in the low-velocity limit, to the electronic properties of the crystal as described using a LCAO method. All the parameters appearing in Eq. (9), the general equation giving the stopping power, can be obtained from the local wave functions of the atom s form ing the crystal. Equation (9) has been applied to the case of He moving in alkalimetals. He is a simple atom, but the alkalimetals present a strong test to our method as their atom ic wave functions interact strongly with each other up to large separations. In Sec. IV, we have presented our results and have found that the stopping power for He is very well described with our local LCAO approach, if the interaction between dierent alkalimetal atom ic orbitals is included, at least, up to fin neighbor.

We conclude that the LCAO method discussed in this paper o ers the possibility of calculating accurately the stopping power for ions moving in solids. This could be a convenient fram ework for analyzing solids having localized d bands and for discussing speci c geometries like the case of atom s moving near surfaces, or the channeled case discussed in Sec. V.

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FIGURES

FIG.1. He moving inside a metal.

FIG.2. Schematic representation of a He atom interacting with a metal band simulated by a metal level $E_{\rm M}$.

FIG.3. Stopping power for He moving inside a Na crystal along the [100]-direction. The stopping power is normalized with respect to its mean value. The coordinates correspond to a (100) plane perpendicular to the projectile trajectory. The atom ic rows along the [100] direction are projected onto the points having the coordinates: (0,0), (0,1), (1,1), (1,0) and, (0.5,0.5).

TABLES

	FEG	LCAO-I	LCAO-II
<u>1 dE</u> (a.ม.)	0.140	0.007	0.056

TABLE I. Stopping power for He in Na as calculated for the free electron m odel (FEG), the LCAO m odelneglecting the m etalwave functions overlaps (LCAO -I), and the LCAO m odeltaking into account these overlaps (LCAO -II).

	(a)	(c)	(C)
Li	0.260	0.110	0.100
Na	0.085	0.068	0.053
К	0.026	0.023	0.023
Rb	0.015	0.015	0.016

TABLE II. Stopping power in a.u. for He in di erent alkali metals. (a) Our results, as calculated using M onte C arb techniques. (b) Our results with the s ocupancy correction. (c) ENR, from Ref. [11].

	atom ic units
S (0,0,0)	0 : 85 10 ¹
S (0,1,1)	018 10 ¹
S (0,0,2)	0:04 10 ¹

TABLE III. Stopping Power for He in Na for the channeled direction [100]